PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application Of: Jhon Jhy Liaw

Examiner: Leigh M. Garbowski

Serial No.: 10/823,822

Group Art Unit: 2825

Filed: 04/15/2004

Confirmation No.: 5620

For: METHOD FOR USING ASYMMETRIC OPC STRUCTURES ON LINE ENDS OF

SEMICONDUCTOR PATTERN LAYERS

NOTICE OF ALLOWANCE Dated: 07/27/2006

SUBMISSION OF CORRECTED DRAWINGS

Dear Sir:

Enclosed please find one replacement sheet 1/2 containing corrected Figs. 1A, 1B, 1C. These drawings are being submitted to indicate "(PRIOR ART)" as agreed upon in the Examiner's Amendment.

Please charge any associated underpayment or credit any overpayment to Deposit Account 04-1679.

Respectfully submitted,

Dated: _ [0 - 27 - 06

Steven E. Koffs, Esquire Registration No. 37,163

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